

CuCo₂O₄ nanoneedle array with high stability for high performance asymmetric supercapacitors

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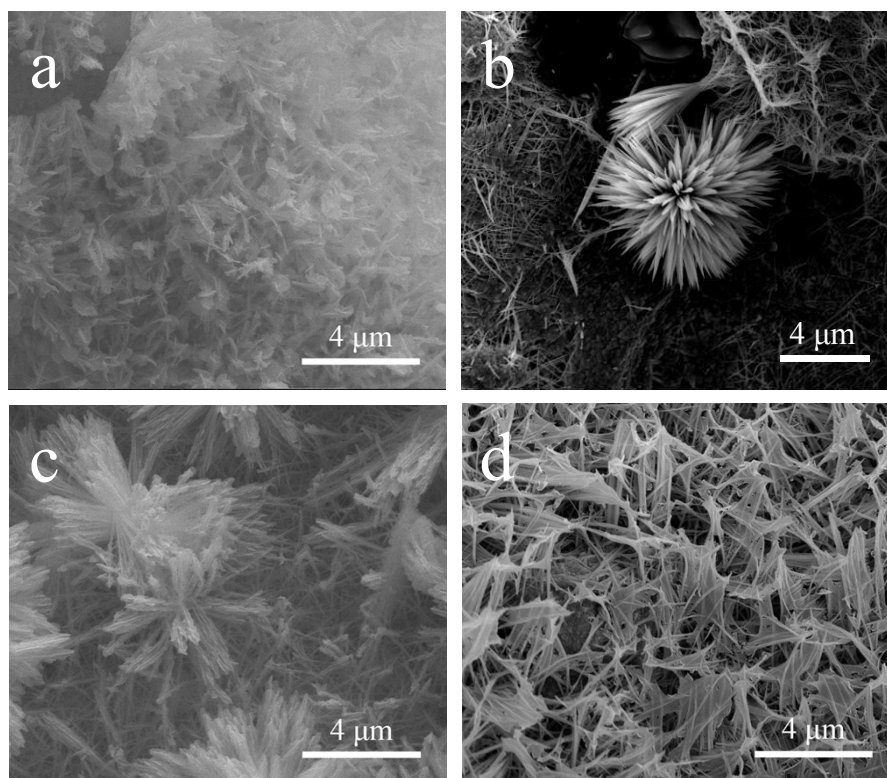


Fig. S1. SEM images of (a) $\text{CuCo}_2\text{O}_{4-3}$, (b) $\text{CuCo}_2\text{O}_{4-6}$, (c) $\text{CuCo}_2\text{O}_{4-9}$, (d) $\text{CuCo}_2\text{O}_{4-15}$.

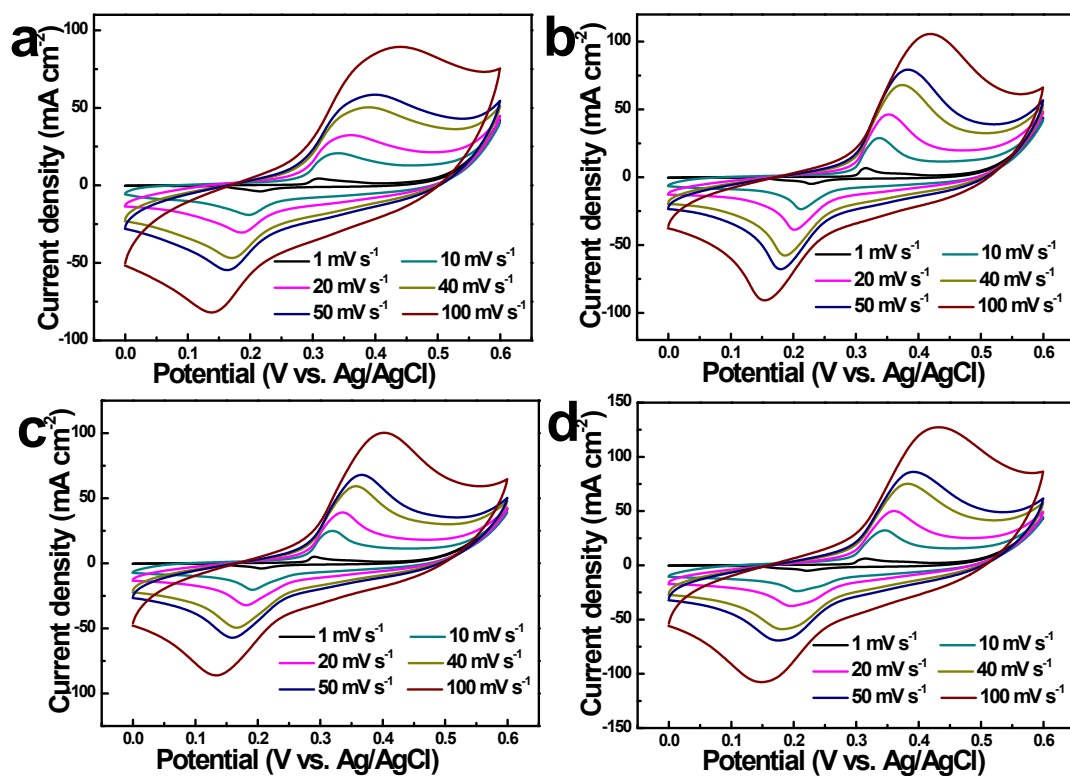


Fig. S2. CV curves of (a) CuCo₂O₄-3, (b) CuCo₂O₄-6, (b) CuCo₂O₄-9, (c) CuCo₂O₄-15 electrodes at various scan rates.